

GEMOLOGICAL INSTITUTE

## **ELECTRONIC COPY**

## LABORATORY GROWN DIAMOND REPORT

## PROPORTIONS

**CLARITY CHARACTERISTICS** 

**KEY TO SYMBOLS** 

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

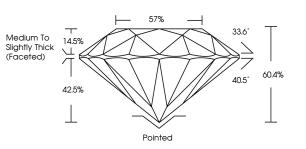
July 12, 2024	
IGI Report Number	LG635455689
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	ROUND BRILLIANT
Measurements	6.64 - 6.68 X 4.02 MM
GRADING RESULTS	
Carat Weight	1.09 CARAT
Color Grade	E CITAL CITAL
Clarity Grade	VVS 2
Cut Grade	IDEAL
ADDITIONAL GRADING	NEORMATION

#### ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	∬⁄⊊∫ LG635455689

Comments: As Grown - No indication of post-growth treatment.

This Laboratory Grown Diamond was created by High Pressure High Temperature (HPHT) growth process. Type II



LG635455689

Report verification at igi.org



Sample Image Used

# July 12 2024

524	
t Number	LG635455689
n LABORATO	ORY GROWN DIAMOND
nd Cutting Style	ROUND BRILLIANT
ments	6.64 - 6.68 X 4.02 MM
RESULTS	
eight	1.09 CARAT
de	E
ade	VVS 2
le	IDEAL

LABORATORY GROWN DIAMOND REPORT

57% 33.6° 14.59 Medium To Slightly 60.4% Thick 40.5° 42.5% (Faceted) Pointed

#### ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
nscription(s)	(67) LG635455689
Comments: As Grown - No inc treatment. This Laboratory Grown Diamor Pressure High Temperature (HF Type II	nd was created by High





# COLOR

DEF	GHIJ	Faint	Very Light	Light
CLARITY	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	I <sup>1-3</sup>
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included
lawless	Slightly Included	siigniiy incluaea	Included	
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